Atom-by-atom nano structuring and single-atom chemical identification at room temperature



#### National Institute for Materials Science (Tsukuba, Japan)





"In Touch With Atoms" G. Bining & H. Rohrer Rev. Mod. Phys. <u>71</u> 5324, (1999)

#### Collaborators



#### Outline

- Brief introduction to experimental technique: FM-AFM
- Nano-structuring atom by atom using AFM
  - Lateral interchange atom manipulation
  - Vertical interchange atom manipulation
- Chemical identification of individual atoms with AFM

#### Summary

## Instrumentation

#### Atomic resolution dynamic force microscopy

**Frequency-Modulation AFM** Length ~225 µm (Non-contact AFM) Width ~38 µm Thickness ~7 µm Height ~12 µm A 08

#### Atomic resolution dynamic force microscopy

#### Cu(100) and Cu(111)



Ch. Loppacher et al., Phys. Rev. B, 62, 16944 (2000)

#### Ge(111)-c(2×8)



 $(5.0 \times 5.0)$  nm<sup>2</sup> T = 80K



#### **CeO**<sub>2</sub>(111)



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#### **UHV-AFM & Interferometric Detection**



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#### Frequency Modulation Detection Method



# Nano structuring atom by atom at room temperature

#### Nano structures by atom manipulation



D. M. Eigler, C.P. Lutz et al. IBM Almaden Research Center (USA)





F. J. Giessibl Science 267 68 (1995).

# Can we manipulate atoms with the AFM?



#### First Demonstration of Atom Manipulation with AFM

First demonstration of the AFM capability for the manipulation of individual atoms



- Substitutional Sn atoms on the Ge(111)-c(2x8) surface
- More than 120 manipulation events in a 9 hours experiment performed at room temperature
- These patterns remain stable at the surface for long periods of time: a minimum mean lifetime of 25 hours is estimated for these structures

#### Controlling the natural diffusion energy barriers





 Nature Materials
 4
 156 (2005)

 Nature Nanotecnology
 4
 803 (2009)

#### Manipulation protocol and mechanism

- Manipulation procedure:
  - > Appropriate selection of the tip scan direction
  - >Tuning the tip-surface interaction force



 $(4.6 \times 4.6) \text{ nm}^2$  $\Delta f = -8.3 \text{Hz}$ 





NC-AFM topographic images:

 $f_0 = 169430.0 \text{ Hz}$  A = 17.6 nm K<sub>L</sub> = 34.8 N/m RT

Nature Materials <u>4</u> 156 (2005) Nature Nanotecnology <u>4</u> 803 (2009)

#### Reproducibility in other surfaces

Sn/Si(111)-( $\int 3x \int 3$ )R30° at room temperature





A = 33.1 nm

 $K_{L} = 35.4 \text{ N/m}$ 





 Nature Materials
 4
 156 (2005)

 Nature Nanotecnology
 4
 803 (2009)

#### Lateral interchange atom manipulation on different surfaces



Sn/Ge(111)-c(2x8)



Sn/Si(111)-(√3x√3)R30



#### In/Si(111)-(J3xJ3)R30



Sb/Si(111)-(7x7)

Nature Materials <u>4</u> 156 (2005) Nature Nanotecnology <u>4</u> 803 (2009)

### Interchange atom manipulation



## Vertical interchange manipulation

#### Vertical interchange manipulations in the Sn/Si







- Original





----- After Sn deposition





Science 322 413 (2008) Nature Nanotecnology <u>4</u>803 (2009)

 $f_0 = 193738.0 \text{ Hz}; \text{ A} = 21.9 \text{ nm}; \text{ K}_L = 48.8 \text{ N/m}; \Delta f = -7.3 \text{ Hz}$ 

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#### Reproducibility of these manipulations

Consecutive alternate vertical interchange manipulations



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#### Manipulation mechanism: DFT simulations



#### Typical barriers involved in these vertical manipulations



#### Atomic pencil

We could, in principle, "write" with atoms



Erase (Sn deposition)





Plot (Si deposition)



Construction time: 1.5 hours



## Chemical identification of individual atoms with AFM



#### Searching for atomic chemical specificity with SPM



"In Touch With Atoms" G. Bining & H. Rohrer Rev. Mod. Phys. <u>71</u> 5324, (1999)

Volume 49, Number 1	PHYSICA	AL REVIEW LETTERS	5 JULY 1982	
S	urface Studies by	Scanning Tunneling Microscopy	Ε.	
IBM 2	G. Binning, H. Ro Zurich Research Lab (Red	ohrer, Ch. Gerber, and E. Weibel oratory, 8803 Rüschlikon-ZH, Switzerland ceived 30 April 1982)		
Surface micro graphic picture monoatomic ste and Au.	oscopy using vacuum s of surfaces on an <i>a</i> eps and surface recor	tunneling is demonstrated for the first time. <i>tomic scale</i> have been obtained. Examples of nstructions are shown for (110) surfaces of Ca	Topo- f resolved alrSn <sub>4</sub>	
PACS numbers	68.20.+t, 73.40.Gk			
VOLUME	56, NUMBER 9	PHYSICAL REVIEW LETTE	RS	3 MARCH 198
		Atomic Force Microscope		
	Edward	G. Binnig <sup>(a)</sup> and C. F. Quate <sup>(b)</sup> d L. Ginzton Laboratory, Stanford University, Stanford	d, California 94305	
		and		
		Ch. Gerber <sup>(c)</sup> IBM San Jose Research Laboratory, San Jose, Calife (Received 5 December 1985)	ornia 95193	
	The scanning tu N. As one applica gating surfaces of the principles of th probe that does no tion of 30 Å and a	nneling microscope is proposed as a method to me ation for this concept, we introduce a new type of insulators on an atomic scale. The atomic force n he scanning tunneling microscope and the stylus p ot damage the surface. Our preliminary results in a vertical resolution less than 1 Å.	easure forces as small as 10 microscope capable of inven- nicroscope is a combinatio profilometer. It incorporat ir demonstrate a lateral res	0 <sup>-18</sup> esti- n of es a solu-
	PACS numbers: 68.3	35.Gy		

#### Chemical identification with STM: IETS

Kondo resonance, quantum Spin excitation & Single Molecule Vibrational Spectroscopy



B. C. Stipe, M. A. Rezaei, W. Ho Science <u>280</u> 1732 (1998). Courtesy of Sebastian Loth

IBM Almaden Research Center

A. J. Heinrich, et al. Science <u>306</u> 466 (2004).

C. F. Hirjibehedin, et al. Science 312 1021 (2006).

#### Searching for atomic chemical specificity with SPM



"In Touch With Atoms" G. Bining & H. Rohrer Rev. Mod. Phys. <u>71</u> 5324, (1999)



#### Short-range chemical interaction forces: imaging mechanism

- The onset of a covalent bond formation between the outermost tip atom and the surface atoms in semiconductor surfaces.
  - R. Perez, M. C. Payne, I. Štich, and K. Terakura Phys. Rev. Lett., **78**, 678 (1997)



The confined electrostatic interaction between the outermost tip atom (that should have a polar nature) and the opposite polarity atomic species at the surface in insulating (polar) surfaces.

> A.I. Livshits, A.L. Shluger, A.L. Rohl & A.S. Foster Phys. Rev. B 59, 2436 (1999)



M. B. Watkins and A. L. Shluger Phys. Rev. B 73, 245435 (2006) Arrows represent the gradient of the electrostatic potential

#### Bonding forces should bear chemical information



## Precise measurement of short-range forces: Sn/Si(III)



(4.3x4.3) nm<sup>2</sup>

- 100 Af(z) characteristics per force curve.
- Acquisition over the top-most part of the atom with a lateral precision better than ±0.1 Å.
- Atoms in equivalent local surface configuration
- Electrostatic force minimized
- Force conversion from the averaged \Deltaf(z) curve
- Identical analysis protocol



Sets of short-range chemical forces measured over Sn and Si atoms in several sessions using tips-apex terminations with different structure and composition

#### Precise measurement of short-range forces



Only one common feature: the Si curve provides the stronger SR force values

The relative interaction ratio of the maximum attractive short-range force within a set (for the same tip) remains nearly constant independently on the tip

Nature <u>446</u> 64 (2007)

#### Relative interaction ratio of the maximum attractive forces



#### Normalization and relative interaction ratio



#### Not only a property of the Group IV: In & Si





#### First-principles calculations: Sn & Si



Tip 2 Sn The relative interaction ratio seems to be independent of the tip-apex chemical termination

termination



#### The essence of the relative interaction ratio





The relative interaction ratio for two atomic species probed with the same tip, is a quantification of the relative strength these surface atoms have to interact with the outermost atom of the tip apex.

... and this property, almost independent on the tip, can be used as a fingerprints for the chemical identification of individual atoms.

#### A challenging system

A single-atomic overlayer alloy of Group-IV elements on a Si(111) substrate.

> Sn: ~ 33% Pb: ~ 33% Si: ~ 33%

- At this surface these atoms have:
  - > Very similar surface electronic structure
  - > Adsorb on equivalent surface positions  $(T_4)$



- > Intermix randomly
- > Topography dependence on the number of first-neighboring Si atoms

Facing the problem of identifying single atoms with very similar chemical properties and identical adsorption sites at room temperature!!!

Nature <u>446</u> 64 (2007)

### Identification: local homogeneous distribution of Si atoms



Only 10  $\Delta f(Z)$  averaged per force curve

Nature <u>446</u> 64 (2007)

#### Identification: local clustering of Si atoms



Only 10  $\Delta f(Z)$  averaged per force curve

Nature 446 64 (2007)

### Applying AFM to solve scientific or technological problems



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#### Summary

Atomic resolution AFM has become a fundamental tool in nanoscience with enough potential to clarify problems of scientific and technological relevance.







KBr(100)

AFM provides access to the atomic structure of insulating surfaces







Similar atomic-scale results are now starting to be reproduced in liquid environment